



JPW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Takeo KAGAMI et al.

Group Art Unit: 3729

Application No.: 10/773,234

Examiner: T. NGUYEN

Filed: February 9, 2004

Docket No.: 118609

For: METHOD FOR FORMING A RESIST PATTERN OF MAGNETIC DEVICE (AS AMENDED)

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the August 29, 2006 Office Action, please consider the following:

Amendments to the Specification;

Amendments to the Claims as reflected in the listing of claims; and

Remarks.